IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Nakamura et al.

Serial No.: 09/746,228 **Group Art Unit:** 1762

Filed: December 26, 2000 **Examiner:** Markham, W.

#10 Reply 5/16/02

For: TRANSPARENT LAMINATE, METHOD FOR PRODUCING THE SAME, AND PLASMA DISPLAY PANEL

Honorable Assistant Commissioner of Patents
Washington, D.C. 20231

SUPPLEMENTAL AMENDMENT

Sir:

This Amendment is a supplement to the Amendment filed on April 24, 2002, which was responsive to the February 1, 2002 Office Action.

IN THE CLAIMS:

Please amend claim 14 as follows:

14. (Amended) A method for producing a transparent laminate comprising:

preparing a transparent substrate;

depositing a high-refractive-index transparent thin film by a vacuum dry process;

depositing a silver transparent conductive thin film by a vacuum dry process;

repeating forming of the high-refractive-index transparent thin film and the silver transparent conductive thin film at least three times to thereby form at least three combination thin-film layers of the high-refractive-index transparent thin film and the silver transparent conductive thin film successively laminated on a surface of said transparent substrate; and

depositing another high-refractive-index transparent thin film on a surface of said combination thin-film layer by the vacuum dry process,

wherein, when said silver transparent conductive thin films are deposited by the vacuum dry process, temperature T (K) of said transparent substrate at the time of the deposition of said films is set to be in a range $340 \leq T \leq 390$, and deposition rate R (nm/sec) of said silver transparent conductive thin films is set to be $R = (1/40)x(T-300)\pm 0.5$.